

Abstract of the Disclosure

An antireflection film is formed of an organic film, and a hard-coating layer, a high refractive index layer and a low refractive index layer laminated in this order on the organic film. The high refractive index layer is formed of metal oxide particles of ITO with electrical conductivity and TiO_2 with high refractive index, and synthetic resin. A volume percentage of the TiO_2 particles to a total volume of the TiO_2 and ITO particles in the high refractive index layer is 1 to 60%, and a volume percentage of the metal oxide particles to a total volume of the metal oxide particles and the synthetic resin is 20% or more.

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